

Fig. 1

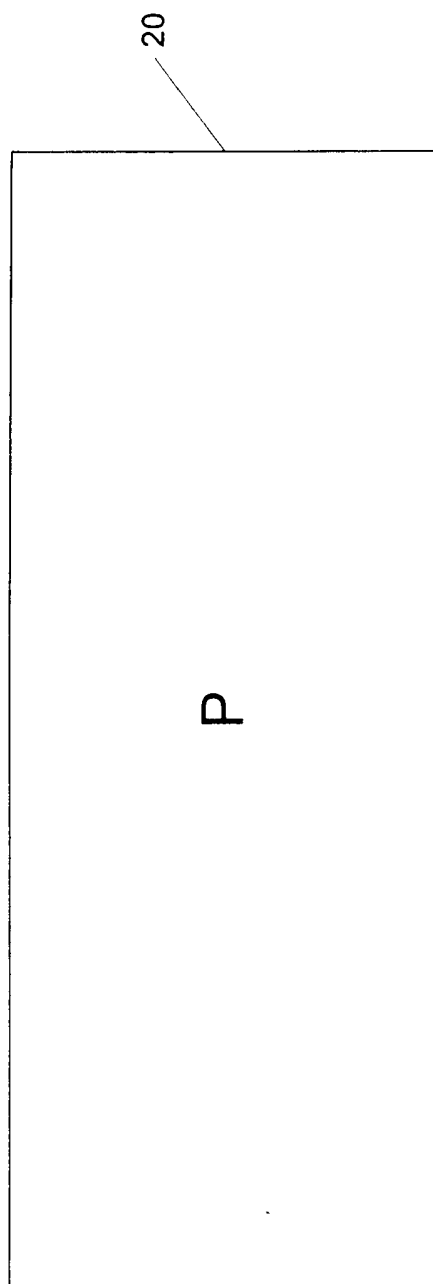


Fig. 2a

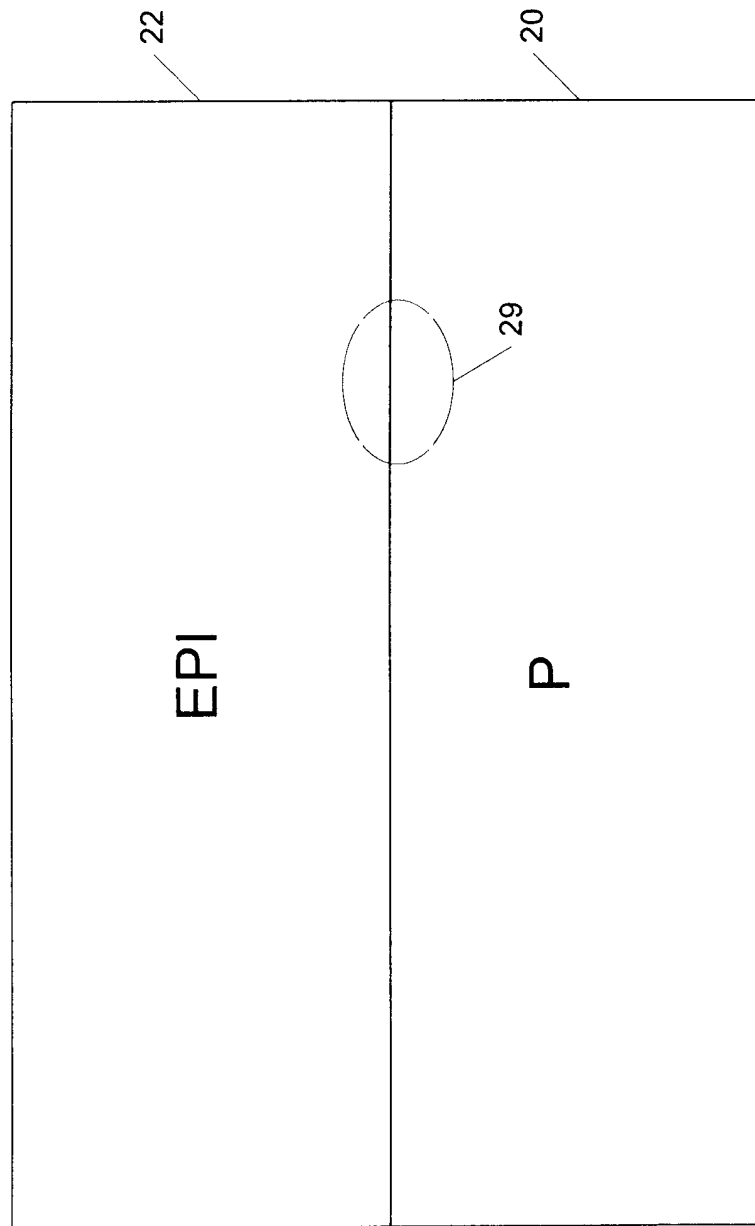


Fig. 2b

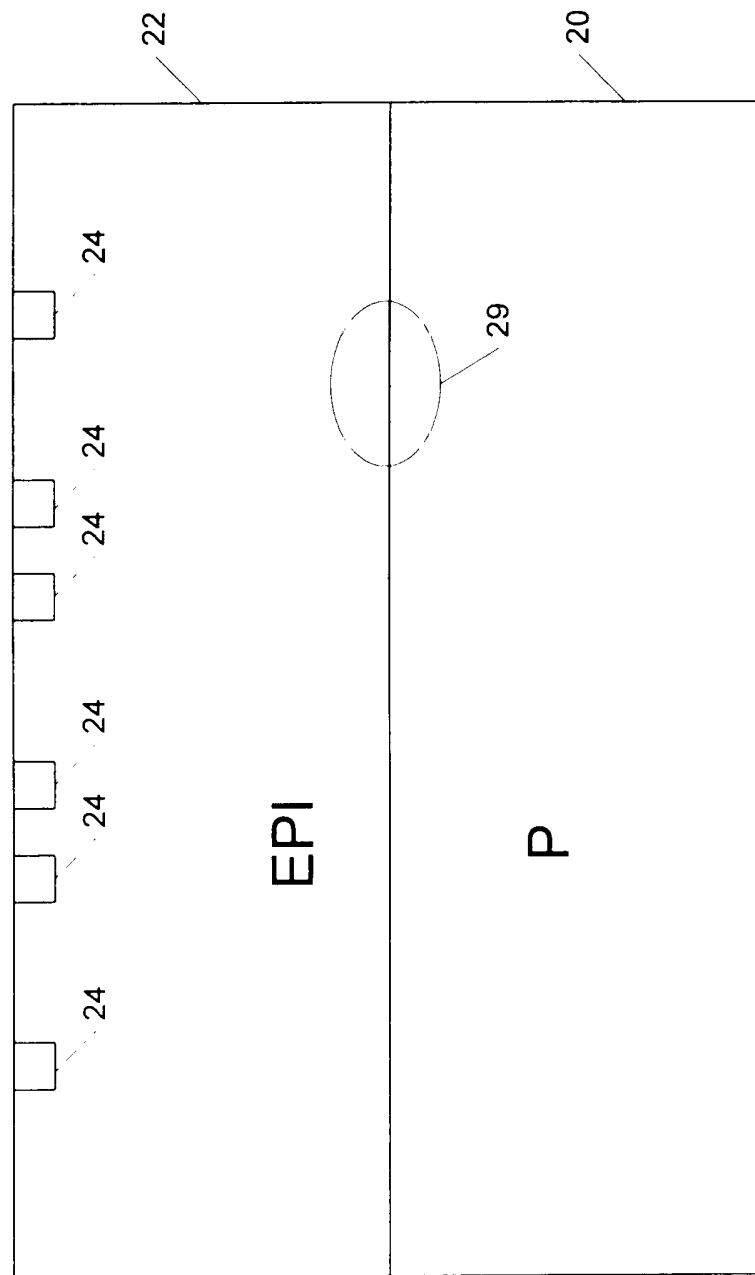


Fig. 2c

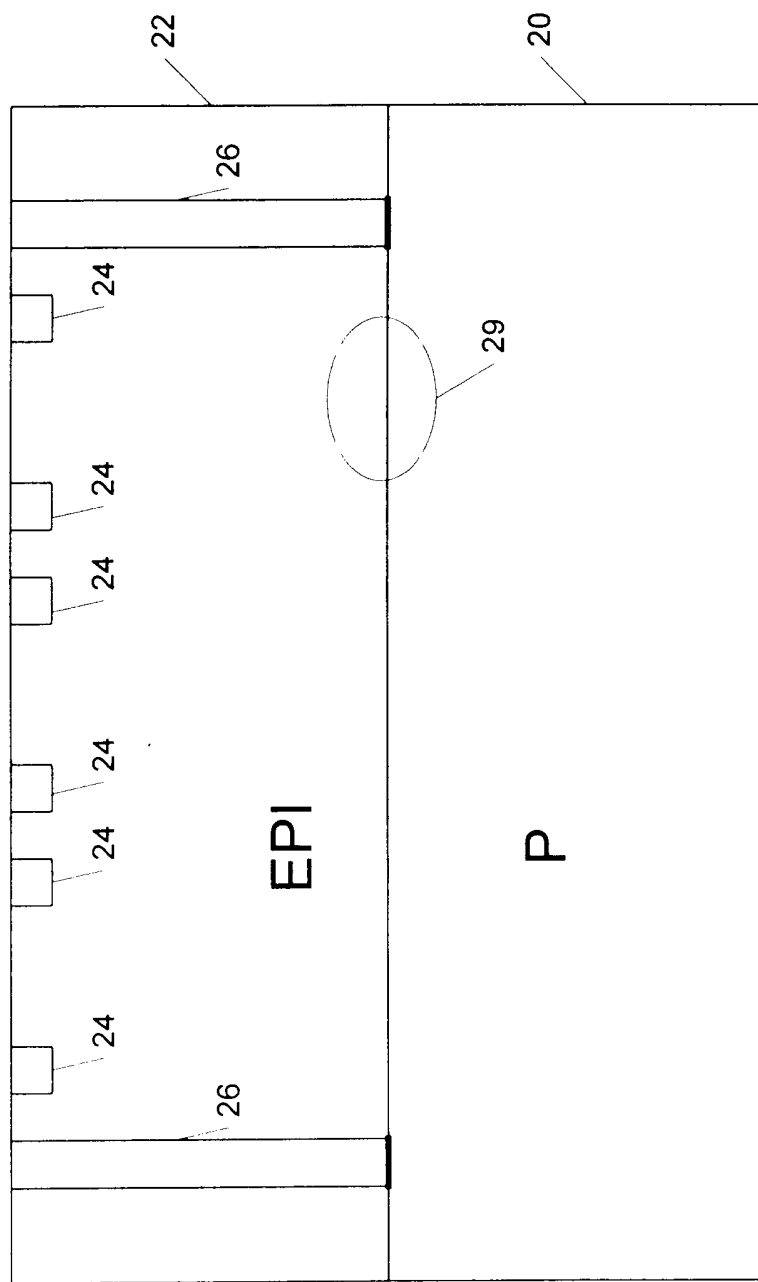


Fig. 2d

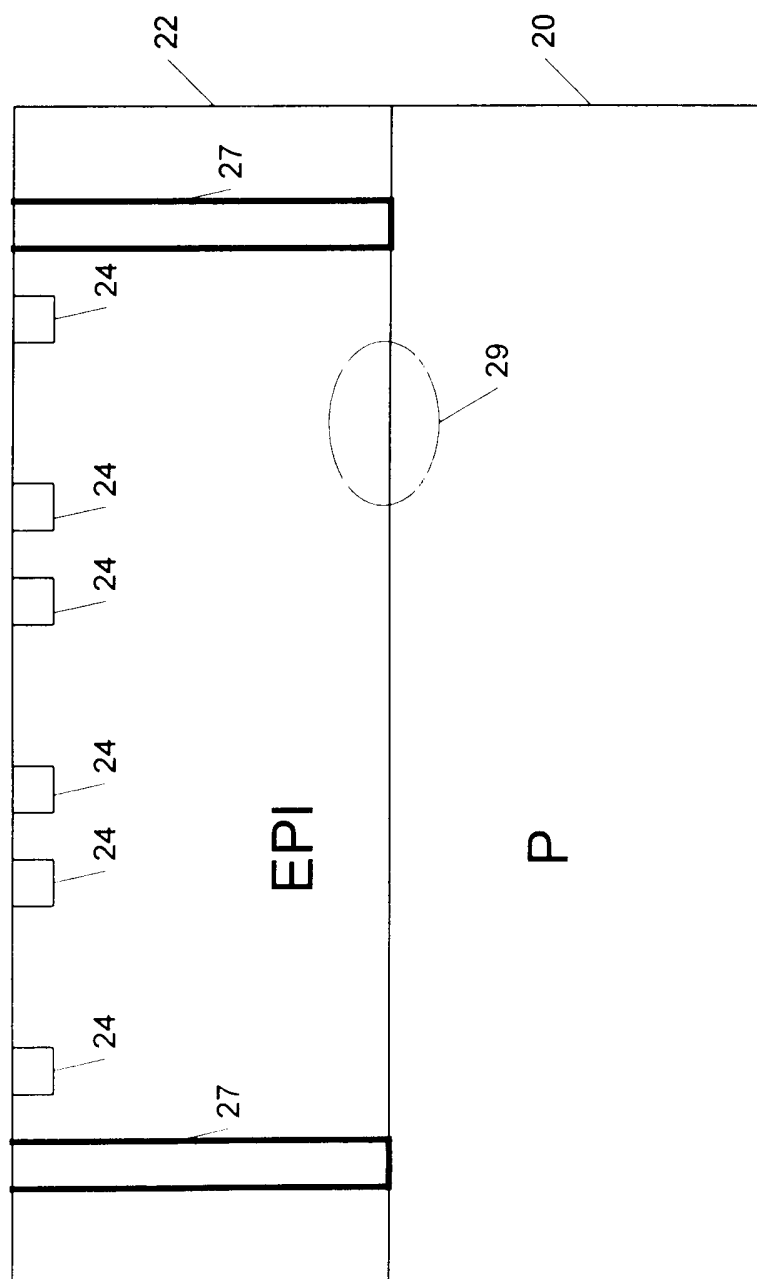


Fig. 2e

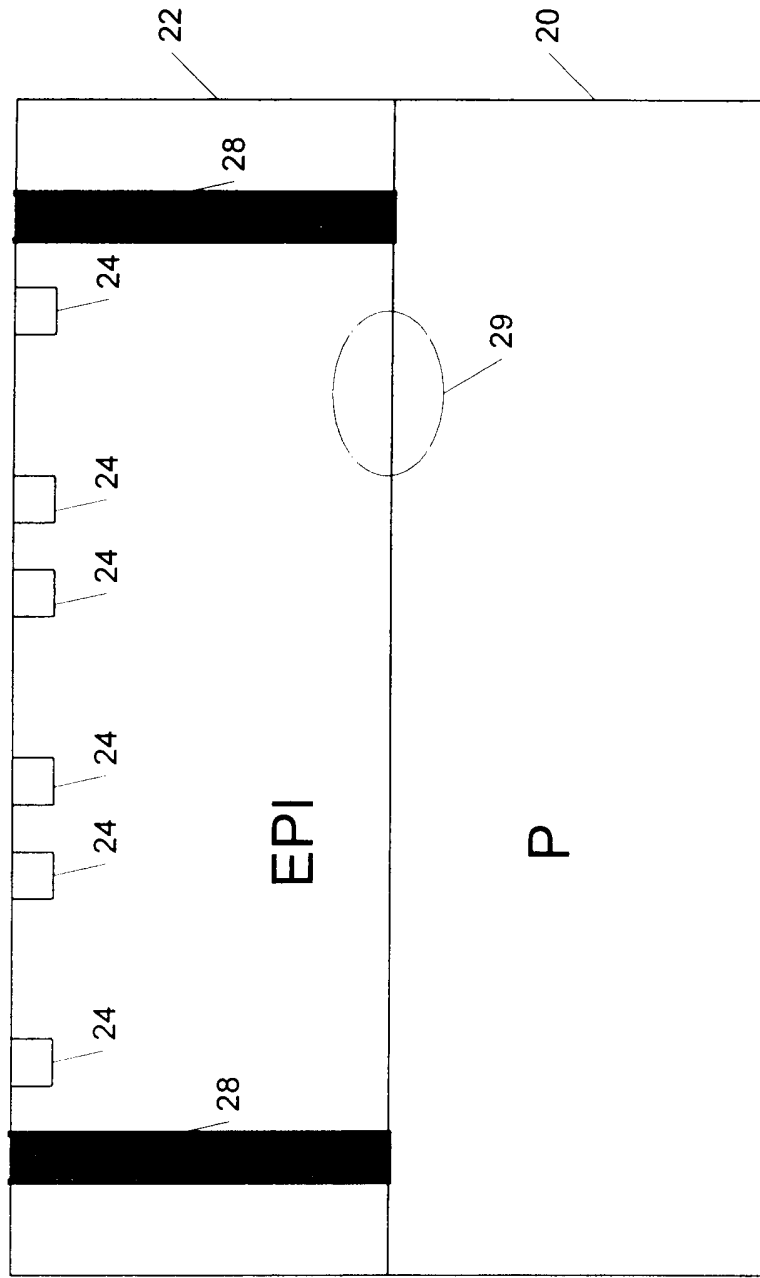


Fig. 2f

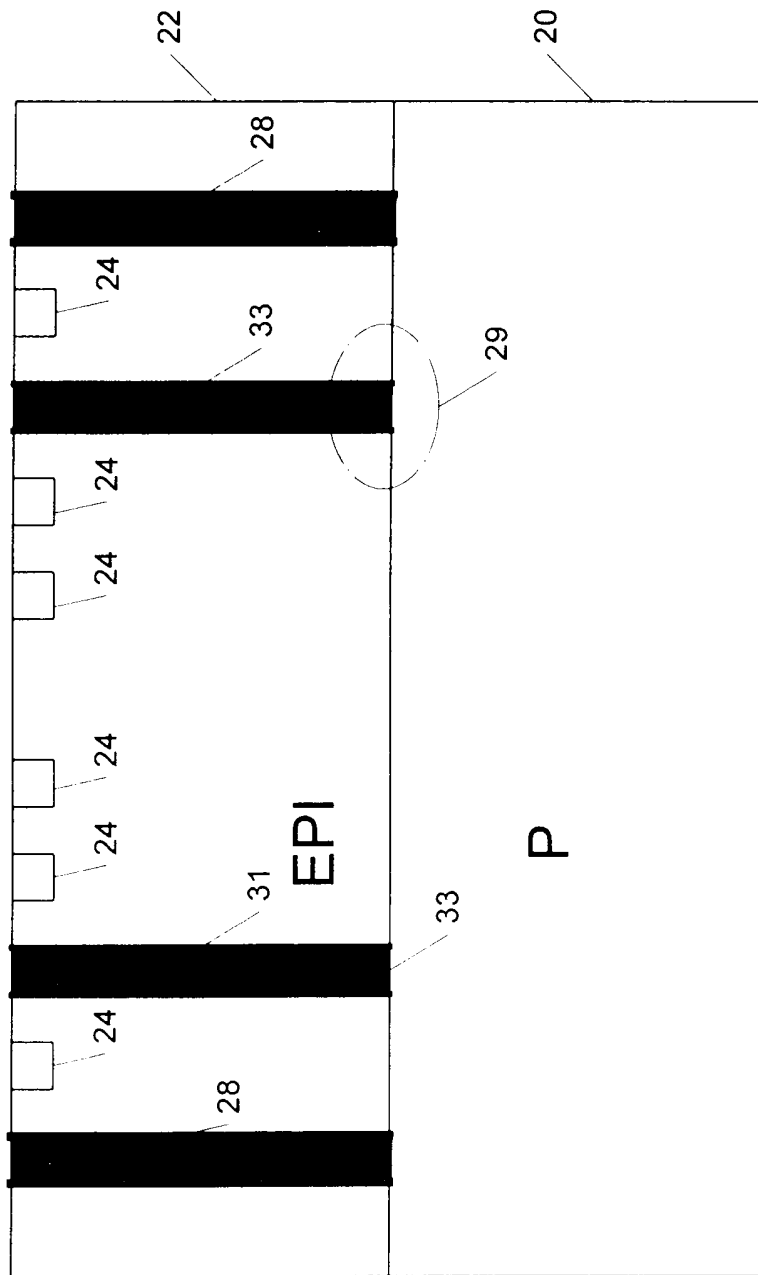


Fig. 2g

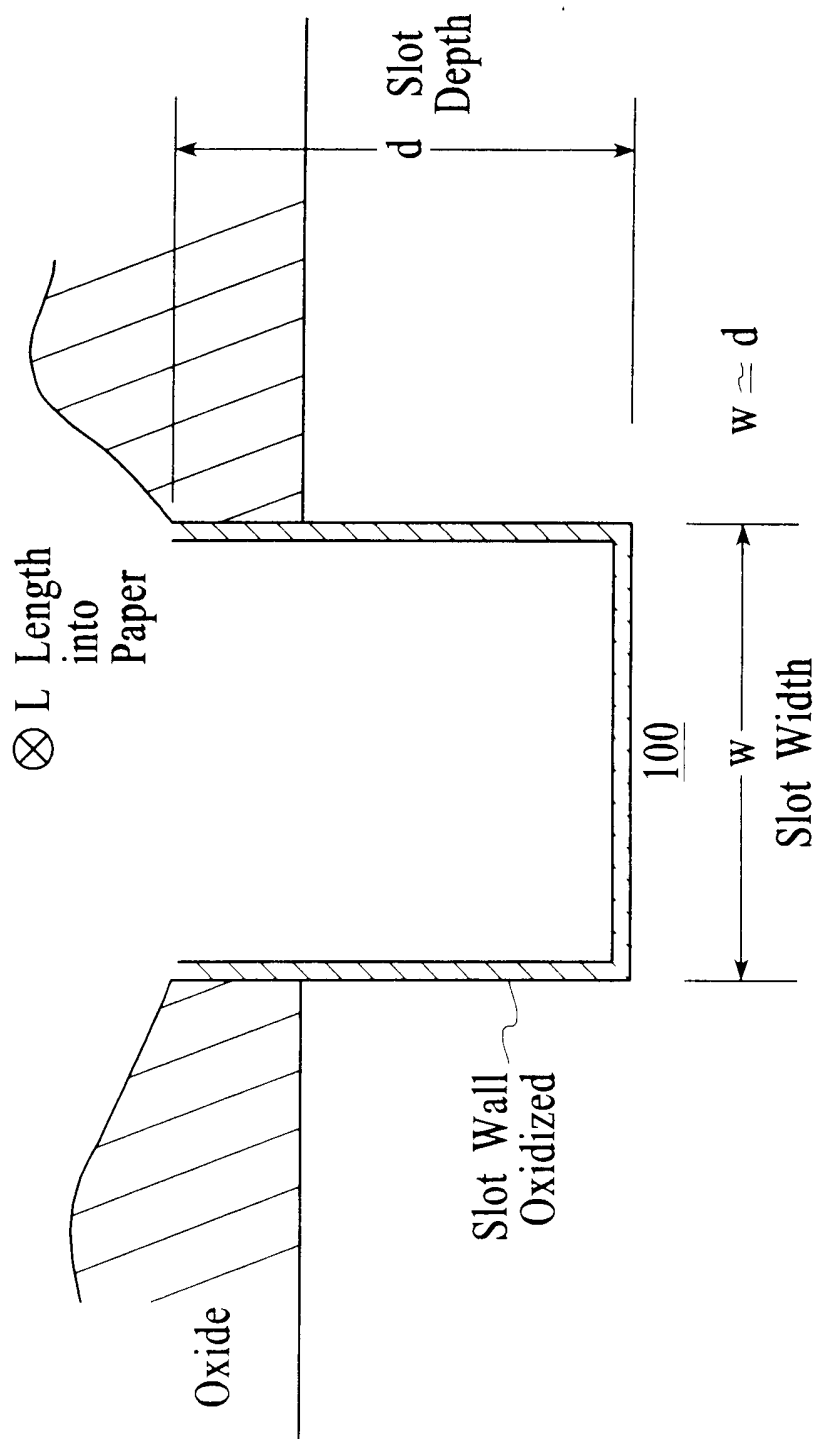


FIG. 3

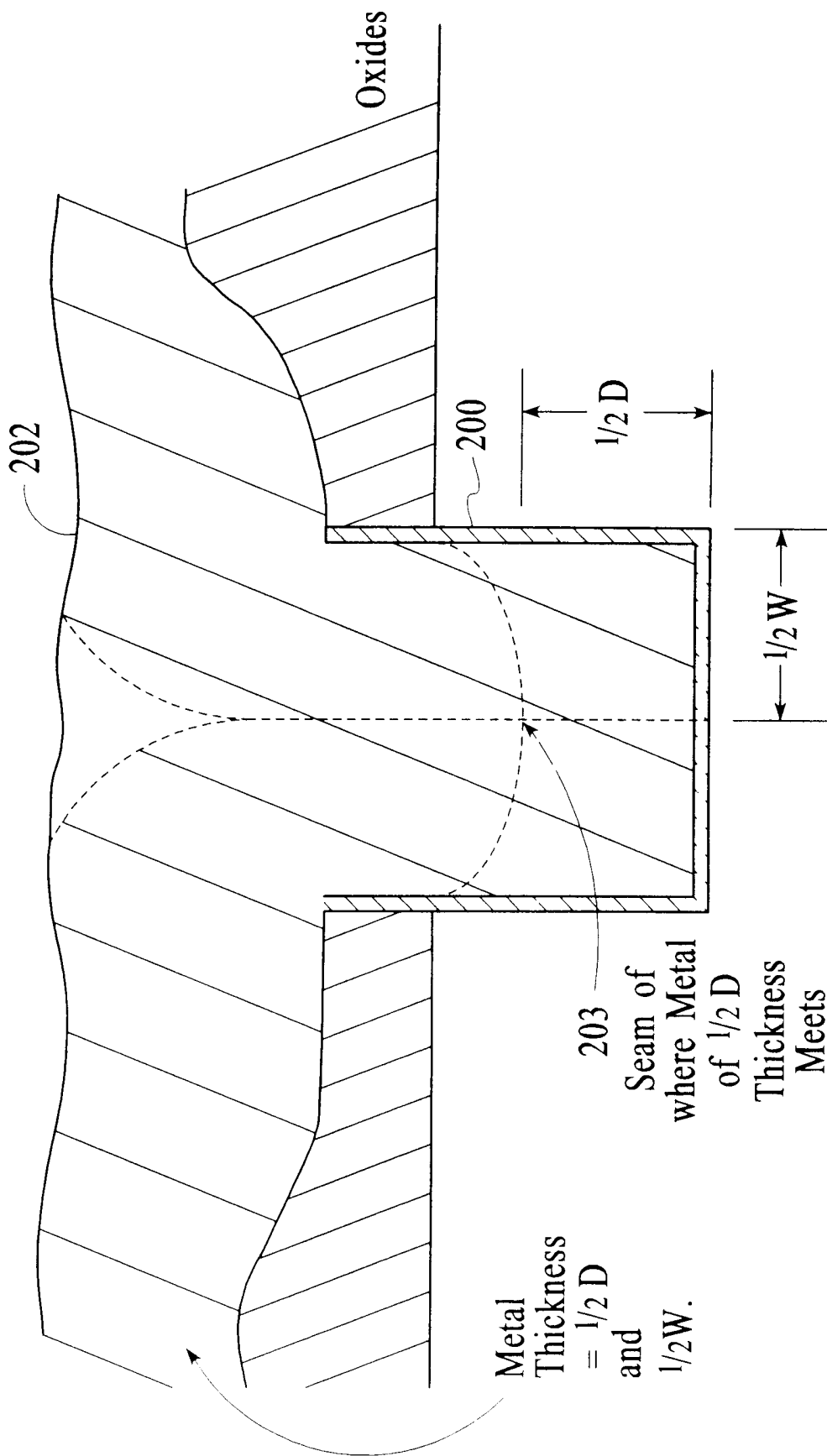
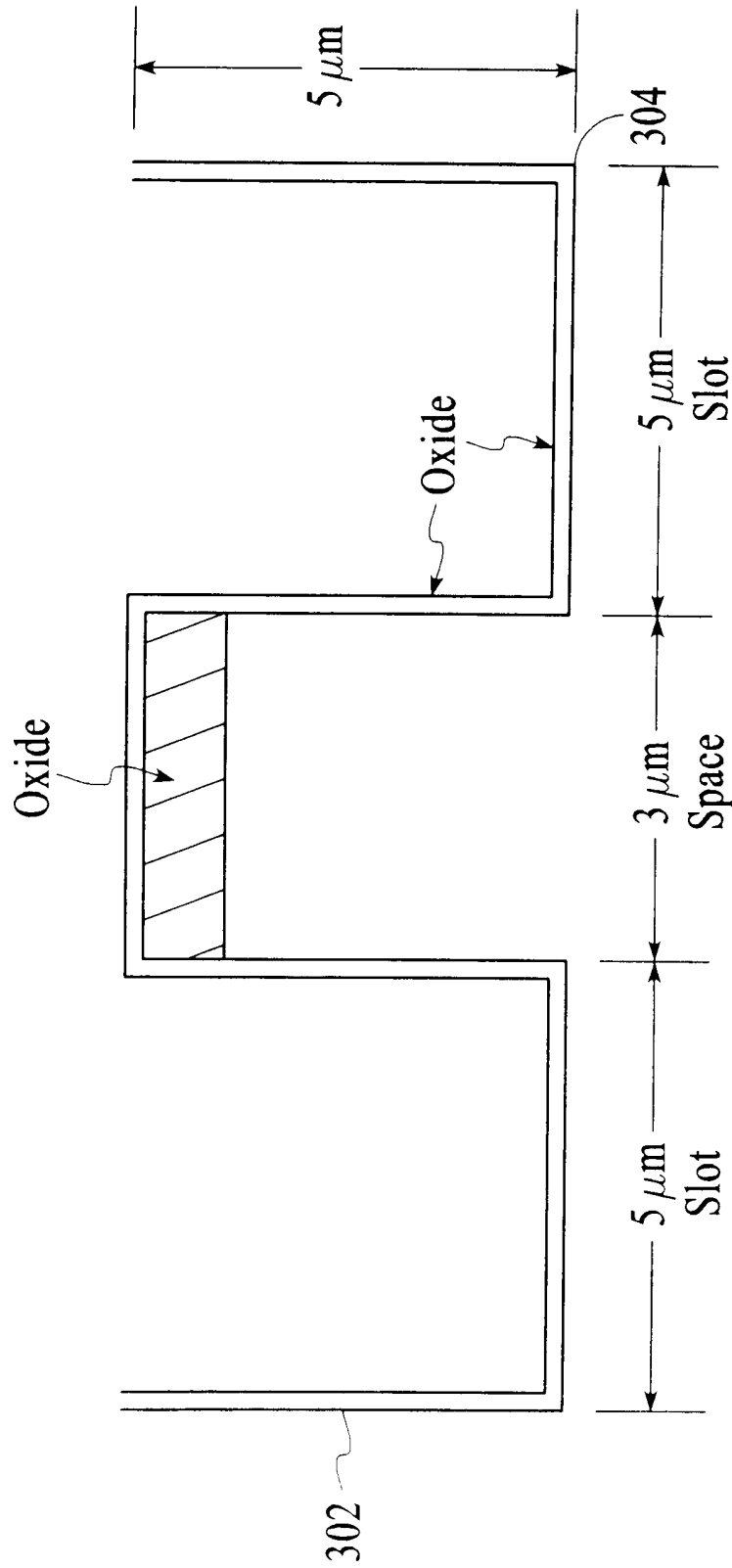
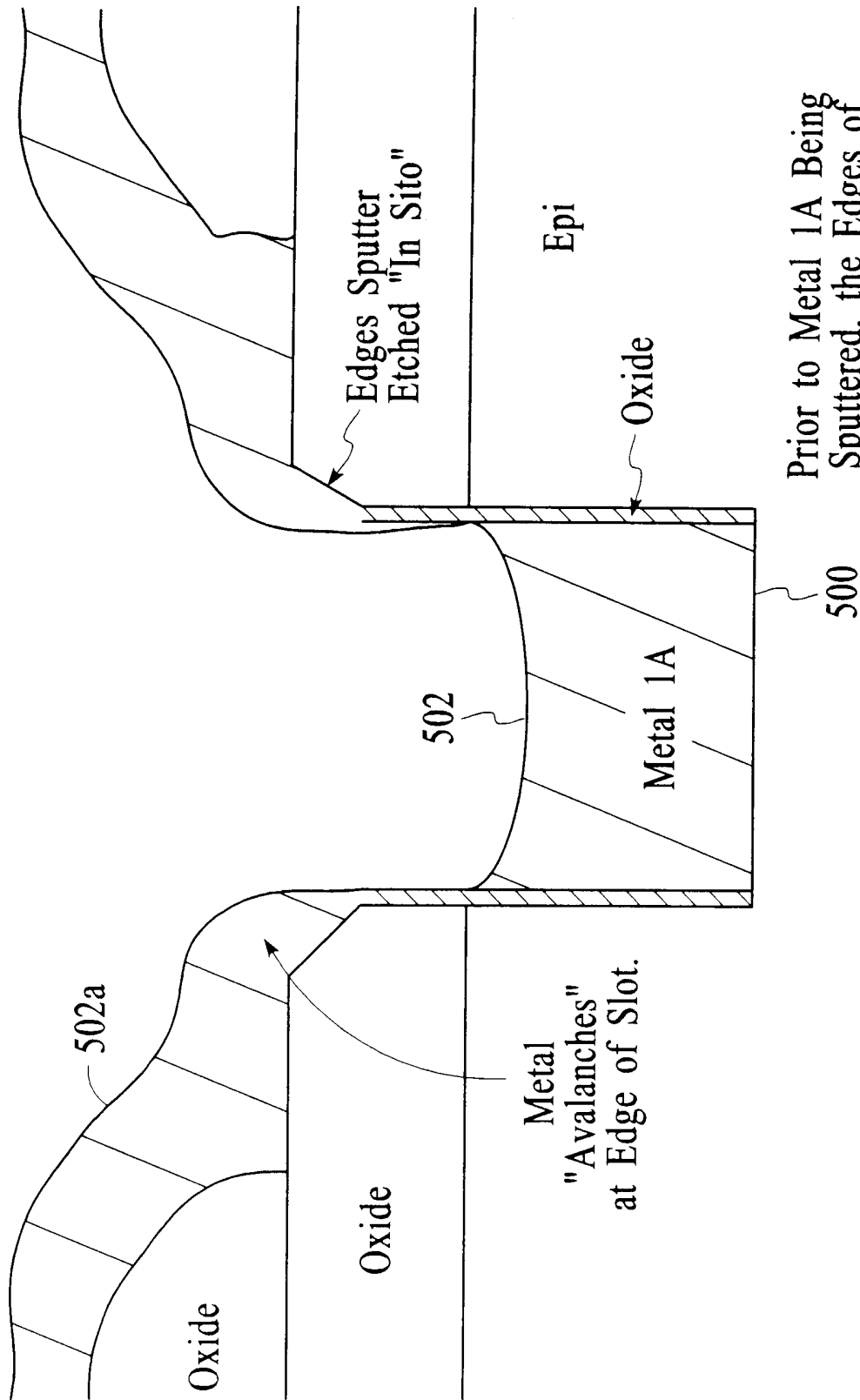


FIG. 4



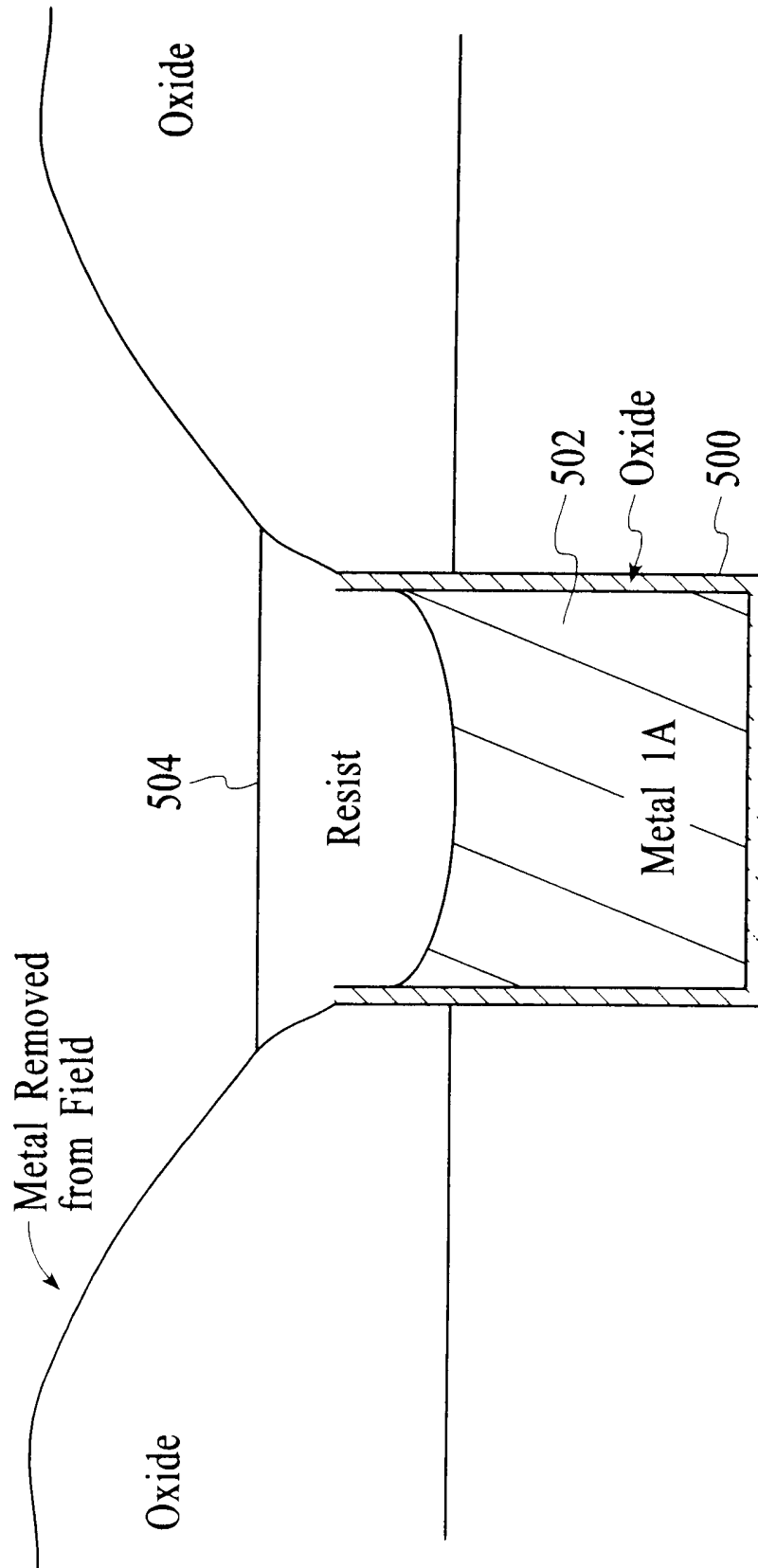
Double Slot for
Double Width of Metal
3 μm Space Between Slots

FIG. 4A



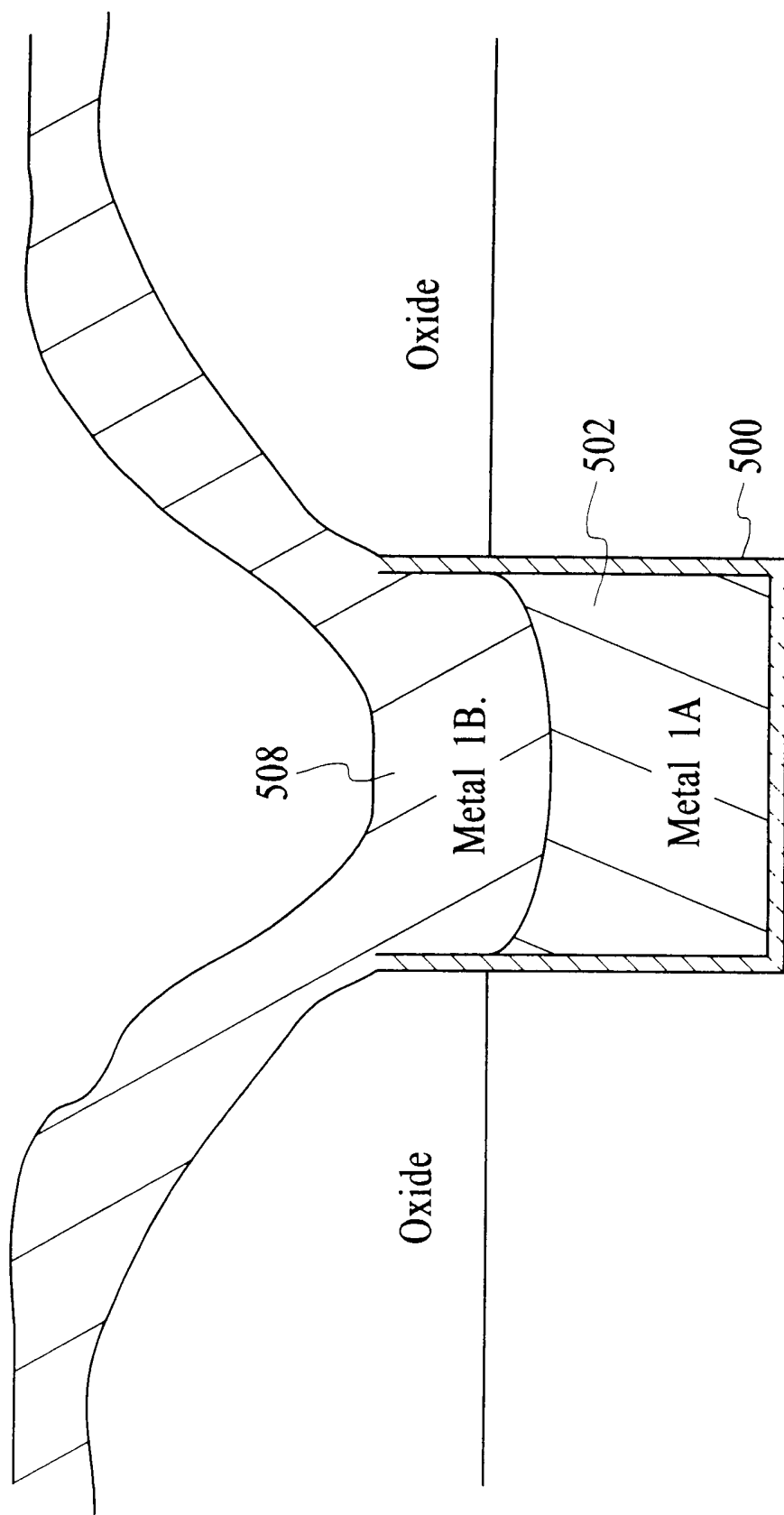
Prior to Metal 1A Being
Sputtered, the Edges of
the Oxides are Sputtered
Etched "In Situ" and
1A Deposited

FIG. 5



Resist Planar Etched Leaving Resist
in Slots. Field Metal Etched Off.

FIG. 7



Resist Stripped & Second Metal 1B
Sputter Deposited

FIG. 8

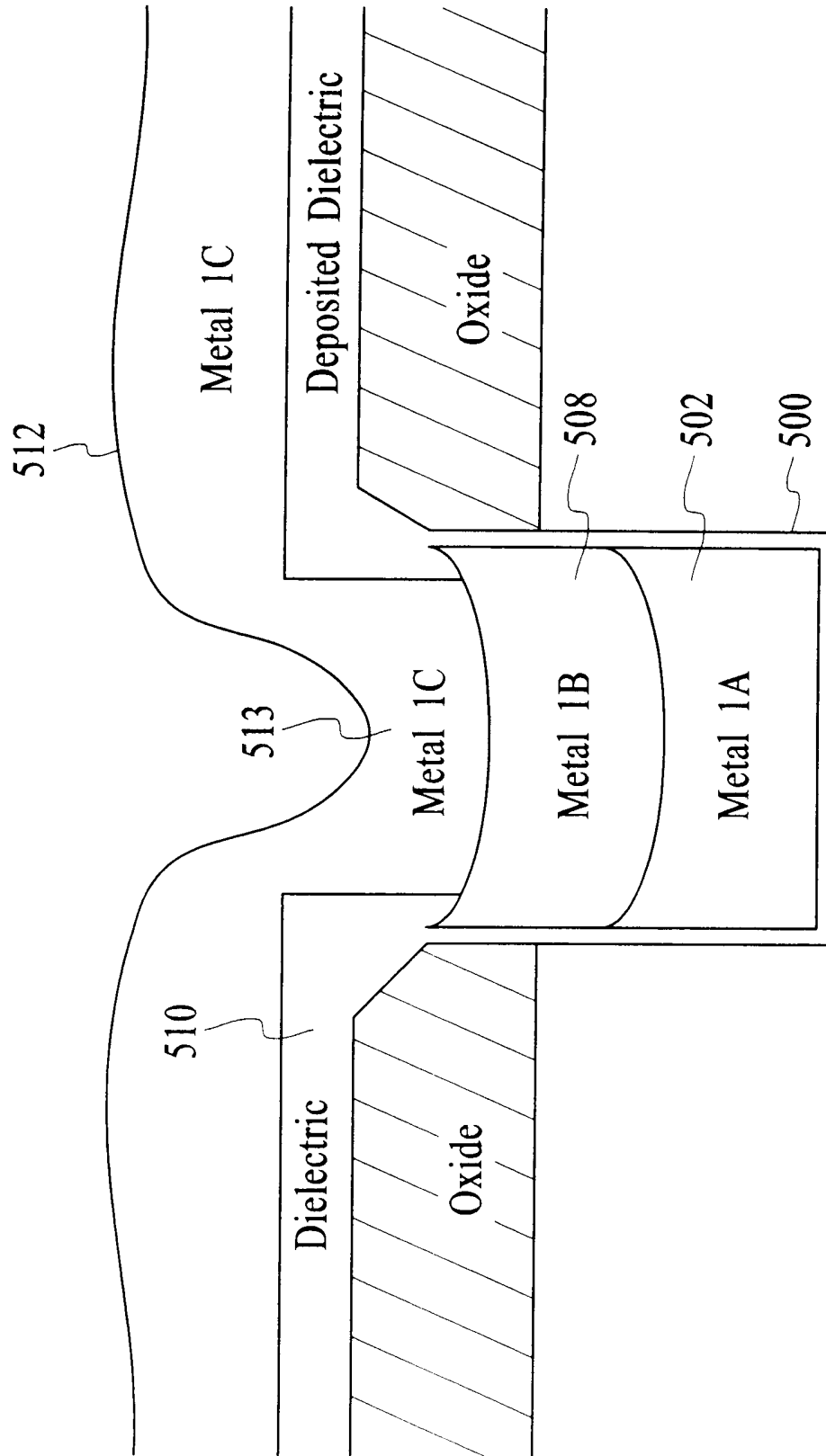


FIG. 9

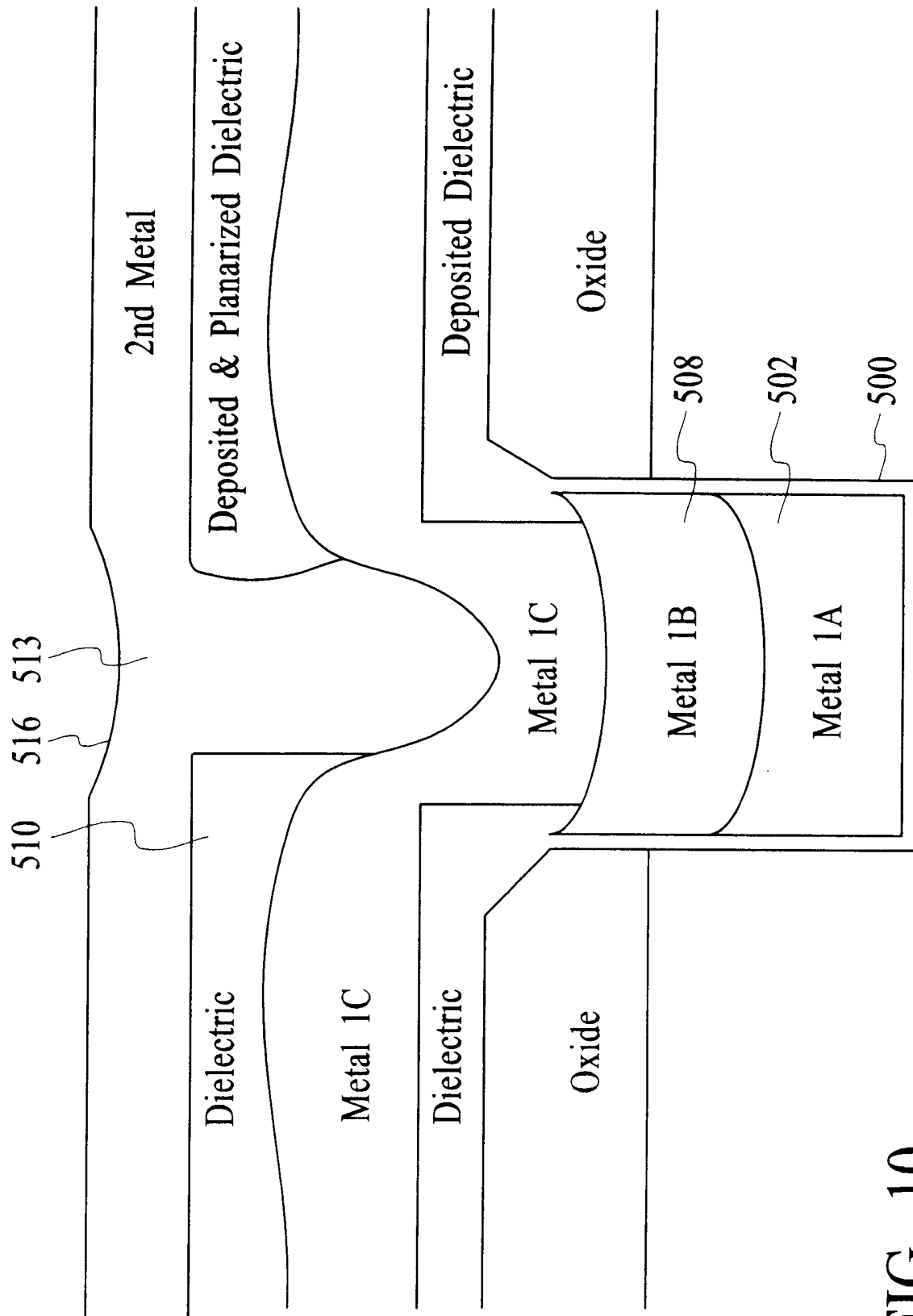


FIG. 10



Power Metal

FIG. 11

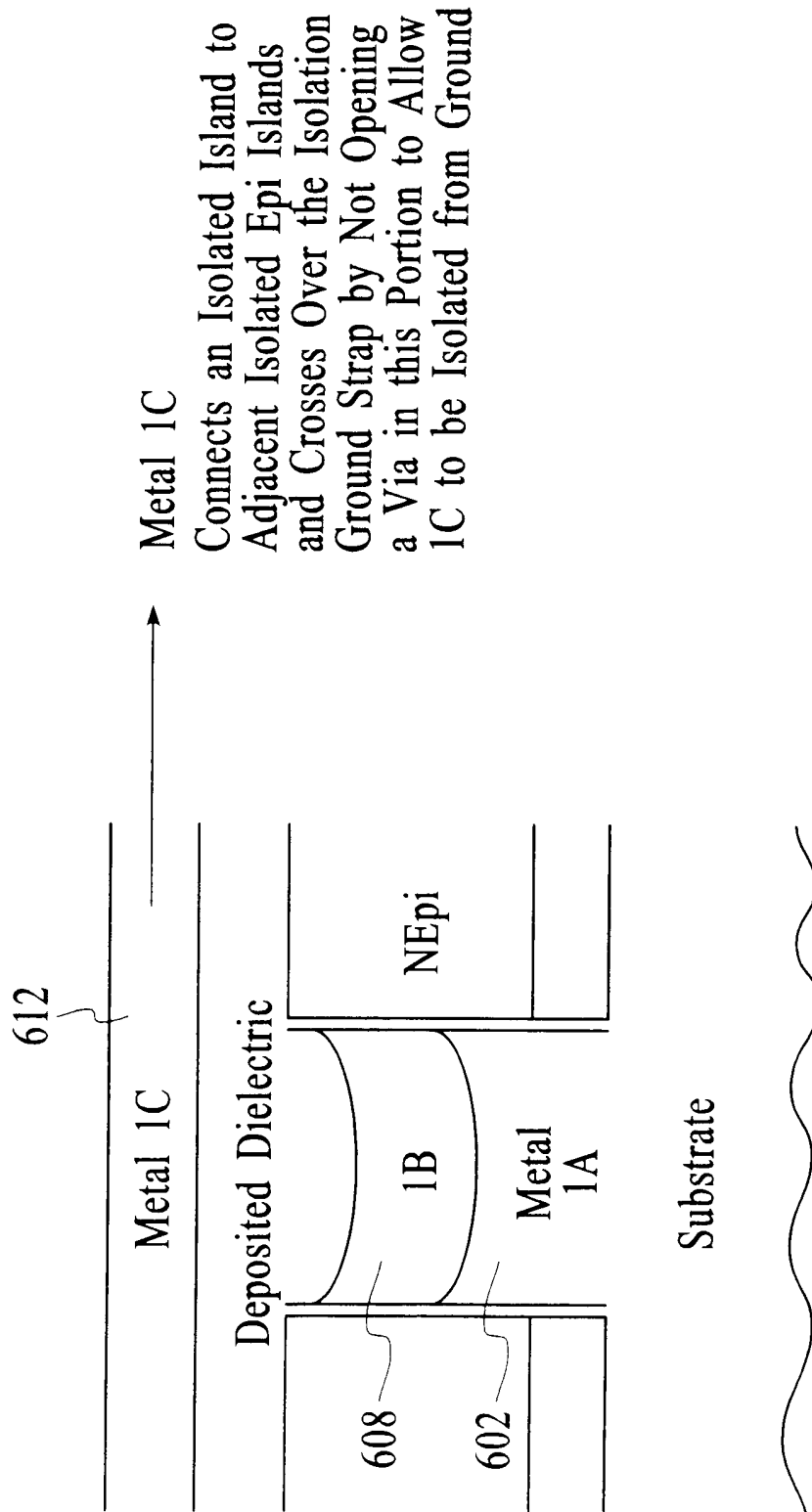


FIG. 12